



09-13-04

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Gonsalves, Kenneth E.
Serial No. : 09/992,560
Filed : November 5, 2001
For : **High Resolution Resists for Next
Generation Lithographies**
Examiner : Lee, Sin J.
Art Unit : 1752

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT PURSUANT TO 37 C.F.R. § 1.116

The following Amendment and Remarks are submitted in response to the Final Office Action mailed June 25, 2004. Please amend the above-identified application as set forth below in order to place the application in condition for allowance.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 13 of this paper.

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